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IN THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the

application:

1. (Currently Amended) A method of cleaning a treatment chamber connected to a

vacuum pump, and a tank of a cleaning agent, comprising:

forming a material including a metal on a wall inside the chamber;

heating the wall;

vaporizing a the cleaning agent comprising one of a carboxylic acid and a derivative

of carboxylic acid;

supplying the vaporized cleaning agent into the chamber; such that the vaporized

cleaning agent contacts the material to form a metal complex of the metal and the cleaning

agent; and

forming a metal complex of the metal and the cleaning agent on the heated wall by

contacting the vaporized cleaning agent with the material;

subliming the metal complex by using a heat source on the heated wall under a

reduced pressure; and

exhausting the sublimed metal complex from the chamber.

2. (Canceled)

3. (Previously Presented) The method of cleaning of claim 1, wherein the cleaning

agent comprises a compound selected from the group comprising RCOOH, RCOOR', and

R(COOH)_n, wherein R, R' are hydrocarbon groups containing halogen atoms, and wherein n

is an integer.

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4. (Previously Presented) The method of cleaning of claim 1, wherein the cleaning

agent comprises trifluoroacetic acid.

5. (Previously Presented) The method of cleaning of claim 1, wherein the treatment

chamber is a component of one of a chemical vapor deposition equipment and a physical

vapor deposition equipment.

6. (Currently Amended) The method of cleaning of claim 1, wherein the metal is copper

wherein in said vaporizing the cleaning agent, the cleaning agent is vaporized by a

vaporizer.

7. (Previously Presented) The method of cleaning of claim 1, further comprising

supplying an additive to the vaporized cleaning agent to promote formation of the metal

complex of the cleaning agent and the metal.

8. (Currently Amended) The method of cleaning of claim 7, wherein the additive

includes oxygen or water vapor.

9. (Currently Amended) A method of cleaning a treatment chamber connected to a

vacuum pump, and a tank of a cleaning agent, comprising:

forming a material including a metal on a wall inside the chamber;

heating the wall;

vaporizing a the cleaning agent comprising one of a carboxylic acid and a derivative

of a carboxylic acid;

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supplying the vaporized cleaning agent into the chamber such that the vaporized cleaning agent contacts the material to form a metal complex of the metal and the cleaning agent;

forming a metal complex of the metal and the cleaning agent on the heated wall by contacting the vaporized cleaning agent with the material;

subliming the metal complex by using a heat source on the heated wall under a reduced pressure; and

repeating said vaporizing the cleaning agent, repeating said supplying the vaporized cleaning agent, repeating said forming the metal complex, and repeating said subliming the metal complex; and

exhausting the sublimed metal complex from the chamber.

10. - 16.(Canceled)

17. (Currently Amended) A method of removing a material including a metal cleaning a treatment chamber connected to a vacuum pump, and a tank of a cleaning agent, comprising:

forming a material including copper on a wall inside the chamber;

heating the wall;

vaporizing a the cleaning agent comprising one of a carboxylic acid and a derivative of carboxylic acid;

forming a metal copper complex on the heated wall by contacting a the vaporized cleaning agent with the material including the metal copper; and

subliming the metal copper complex with a heat source; and exhausting the sublimed copper complex from the chamber.

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18. (Currently Amended) The method of removing cleaning of claim 17, wherein, in said

subliming the metal copper complex, the metal copper complex is heated at a temperature of

at least 150°C.

19. (Currently Amended) The method of removing cleaning of claim 17, wherein, in said

forming a metal a copper complex, the pressure of the vaporized cleaning agent is at least 10

Torr.

20. (Canceled)

21. (Currently Amended) The method of cleaning of <u>claim 17</u> claim 1, further

comprising:

confirming the existence of the material inside the chamber; and

repeating said vaporizing the cleaning agent, repeating said supplying the vaporized

cleaning agent, and repeating said subliming the metal copper complex, if the existence of

material inside the chamber is confirmed.

22. (New) The method of cleaning of claim 17, wherein in forming the material, the

material including copper is formed from Cu⁺¹ (hexafluoroacetylacetonate) and silylolefin

ligand.

23. (New) The method of cleaning of claim 22, wherein the silylolefin ligan is selected

from the group consisting of trimethylvinylsilane (TMVS), dimethoxymethylvinylsilane

(DMOMVS), methoxydimethylvinylsilane (MODMVS), trimethoxyvinylsilane (TMOVS),

triethoxyvinylsilane (TEOVS), ethoxymethoxymethylvinylsilane (EOMOMVS),

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diethoxymethylvinylsilane (DEOMVS), diethoxymethoxyvinylsilane (DEOMOVS), ethoxydimethoxyvinylsilane (EODMOVS), ethoxydiethylvinylsilane (EODEVS), diethoxyethylvinylsilane (DEOEVS), dimethoxyethylvinylsilane (DMOEVS), ethoxydimethylvinylsilane (EODMVS), methoxydiethylvinylsilane (MODEVS) and ethylmethoxymethylvinylsilane (EMOMVS).

- 24. (New) The method of cleaning of claim 9, wherein the cleaning agent is a compound selected from the group comprising RCOOH, RCOOR', and R(COOH)_n, wherein R and R' are hydrocarbon groups containing a halogen atom and n is an integer.
- 25. (New) The method of cleaning of claim 9, wherein the cleaning agent comprises trifluoroacetic acid.
- 26. (New) The method of cleaning of claim 17, wherein the cleaning agent is a compound selected from the group comprising RCOOH, RCOOR', and R(COOH)_n, wherein R and R' are hydrocarbon groups containing a halogen atom and n is an integer.
- 27. (New) The method of cleaning of claim 17, wherein the cleaning agent comprises trifluoroacetic acid.
- 28. (New) The method of cleaning of claim 1, wherein in said heating the wall, the wall is heated at a temperature of at least 300 °C.
- 29. (New) The method of cleaning of claim 9, wherein in said heating the wall, the wall is heated at a temperature of at least 300 °C.

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30. (New) The method of cleaning of claim 17, wherein in said heating the wall, the wall is heated at a temperature of at least 300 °C.